

NEW MEMBERS

ECS is pleased to announce the following new members for July, August, and September 2007.

Active

Toru Abe, Oobushi, Japan
 Petr Baca, Brno, Czech Republic
 Sung-Hyeon Baeck, Incheon, South Korea
 Zhumabay Bakenov, Tokyo, Japan
 Tom Bales, Miami, FL
 Shanhu Bao, Nagoya, Japan
 Francesca Barbagini, Leuven, Belgium
 Florence Bellenger, Leuven, Belgium
 Dmitry Belov, Hsinchu, Taiwan
 Randolph Bernard, New Preston, CT
 Keith Bethune, Honolulu, HI
 Aninda Bhattacharyya, Bangalore, India
 Emek Blair, Fort Collins, CO
 Andreas Boden, Stockholm, Sweden
 David Brunco, Leuven, Belgium
 Rachel Buckle, Abingdon, United Kingdom
 David Calton, Stockport, United Kingdom
 Frank Cassel, Harleysville, PA
 Andy Chan, Norwood, MA
 Ming Chang, NanKai, China
 Michael Chen, Cedar Park, TX
 Fang-Chung Chen, Hsinchu, Taiwan
 Tianniu Chen, Danbury, CT
 Woo-Jae Cheong, Chalk River, Canada
 Sung Won Choi, Seoul, South Korea
 Ricky Chuang, Kaohsiung City, Taiwan
 Martine Claes, Leuven, Belgium
 Steven Consiglio, Albany, NY
 Yi Cui, Stanford, CA
 Cindy Dai, Calgary, Canada
 Maria Daletou, Patras, Greece
 Richard Dashwood, London, United Kingdom
 Despina Davis, Minden, LA
 Pedro de Lima-Neto, Fortaleza, Brazil
 Cinzia De Marco, Agrate, Italy
 Annalisa Del Vitto, Agrate, Italy
 Stephen Downey, Elk River, MN
 Joseph Duimstra, San Carlos, CA
 Fereshteh Ebrahimi, Gainesville, FL
 Victoria Edwards, Corning, NY
 Vladimir Faifer, San Jose, CA
 Milton Feng, Urbana, IL
 Martin Frank, Yorktown Heights, NY
 Ramanan Ganeshanathan, Burlington, MA
 Jason Ganley, Washington, DC
 Guilian Gao, San Jose, CA
 Anne-Marie Goncalves, Versailles, France
 Chaitanya Gupta, Urbana, IL
 Eric Guyer, Menlo Park, CA
 Yasuhiro Haba, Saitama-ken, Japan
 Marcus Halik, Erlangen, Germany
 Yinhua Han, Claremont, CA
 David Hanke, Fallbrook, CA
 Mariappan Hariharaputhiran, Portland, OR
 Amanda Harper-Leatherman, Fairfield, CT
 Akitoshi Hayashi, Sakai, Japan
 Nobuhiko Hojo, Kadoma, Japan
 Michel Houssa, Leuven, Belgium
 Pierre Huet, Dorval, Canada

James Hunter, Plymouth, MN
 Paul Hurley, Cork, Ireland
 Keiji Ishibashi, Tokyo, Japan
 Yoshiyuki Ishii, Kawasaki, Japan
 Yosuke Ishikawa, Southfield, MI
 Nicole Jackson, Independence, OH
 Tom Janssens, Heverlee, Belgium
 Seong Mu Jo, Seoul, South Korea
 Claes Johnson, Stockholm, Sweden
 Andreas Kadavanich, Fremont, CA
 Juri Kato, Nagano-ken, Japan
 Takaaki Kawahara, Hyogo, Japan
 Jiri Kazelle, Brno, Czech Republic
 Jun Kikkawa, Ikeda, Japan
 Gi-Heon Kim, Golden, CO
 Taesung Kim, Suwon-shi, Korea
 Bong-Chull Kim, Chungcheongam-do, South Korea
 Namjun Kim, Stanford, CA
 Won Kim, Gwangju, South Korea
 Kenji Kimura, Sakyō, Japan
 Dhana Lakshmi, Silsoe, United Kingdom
 Christopher Lang, Andover, MA
 Markus Lautala, Vantaa, Finland
 Sung Joo Lee, Singapore, Singapore
 Jong-Won Lee, Columbia, SC
 Hochun Lee, Daejeon, South Korea
 Zilan Li, Heverlee, Belgium
 Pimpa Limthongkul, Klong Luang, Thailand
 Kou-Chen Liu, Tao-Yuan, Taiwan
 Lingyun Liu, Bluffdale, UT
 Jinggang Lu, Raleigh, NC
 Dzmityr Malevich, Kingston, Canada
 Nader Marandian Hagh, Franklin Park, NJ
 Tetsuya Mashio, Kanagawa, Japan
 Artie McKim, Bogalusa, LA
 Latika Menon, Boston, MA
 Svetlana Mitrovski, Charleston, IL
 J. Molina-Contreras, Aguascalientes, Mexico
 Garry Montierth, Fremont, CA
 Sungmo Moon, Kyungriam, South Korea
 Zeki Naal, Ribeirao Preto, Brazil
 Kaoru Nakajima, Sendai, Japan
 Paul Nguyen, San Jose, CA
 Cornelius Nielsch, Hamburg, Germany
 Tatsuo Nino, Hujimino, Japan
 Michael Nispel, Malvern, PA
 Hiroshi Nohira, Tokyo, Japan
 Amrit Panda, Bridgewater, NJ
 David Parker, Wellesley, MA
 Javier Parrondo, Sestao, Spain
 Lionel Peguet, Isbergues, France
 Konstantin Pimenov, South Park, PA
 Chyiu Hyia Poon, Singapore
 Valer Pop, Eindhoven, The Netherlands
 Warren Powell, Columbus, OH
 Ljubo Radic, Tempe, AZ
 Gian-Marco Rignanese, Louvain-la-Neuve, Belgium
 Angel Sanjurjo, Menlo Park, CA
 Elisabete Santiago, Sao Paulo, Brazil
 Hele Savin, TKK, Finland
 Paul Schmidt, Muncie, IN

Wolfgang Schuhmann, Bochum, Germany
 Udo Schwalke, Darmstadt, Germany
 Marie Sedlarikova, Brno, Czech Republic
 Jong Hyun Seo, Goyang, South Korea
 Xi Shan, Cleveland, OH
 John Shaw, Santa Clara, CA
 Xiaoping Shi, Heverlee, Belgium
 Sirivatch Shimpalee, Columbia, SC
 Nathalie Simon, Versailles, France
 Ani Simsek Gokcesu, Houston, TX
 Withana Siripala, Dalugama, Sri Lanka
 Darlene Slattery, Cocoa, FL
 Sean Smith, Rolla, MO
 Stephen Snyder, Clayton, OH
 Yuri Sokolov, Sandy, UT
 Zhiqiang Song, Tarrytown, NY
 Jun Sonobe, Tsukuba, Japan
 Andrew Steinbach, St. Paul, MN
 Chris Stoeckmann, Columbia, SC
 Robert Strub, Wallkill, NY
 Laisheng Sun, Cheyenne, WY
 Johan Swerts, Leuven, Belgium
 Toshiki Tajima, Yokohama, Japan
 Alexandr Talyzin, Umea, Sweden
 Hirokazu Tatsuoka, Hamamatsu-city, Japan
 Ichiro Terada, Yokohama, Japan
 Nicole Thomas, Danbury, CT
 Lora Thrun, Lewis Center, OH
 Antony Trueman, Melbourne, Australia
 Cheng-Hsun Tsai, Pan Chiao City, Taiwan
 Haralampos Tsaprailis, Racine, WI
 William Tyler, Branford, CT
 Akira Uedono, Tsukuba, Japan
 Sven Van Elshocht, Heverlee, Belgium
 Jiri Vanek, Brno, Czech Republic
 John Varcoe, Guildford, United Kingdom
 Ganesh Venugopal, Duluth, GA
 Ingrid Vos, Leuven, Belgium
 Kai Wang, Freeport, NY
 James Woodworth, Beverly Hills, MI
 Aiping Wu, Allentown, PA
 Brian Wysocki, Rockville, MD
 Huili Xing, Notre Dame, IN
 Shunsuke Yagi, Kyoto, Japan
 Wassana Yantasee, Richland, WA
 Deokjoo Yoon, Osan, South Korea
 Jung-Hyun Yoon, Choongnam, South Korea
 Denis Yu, Kobe, Japan
 Henry Yue, Richardson, TX
 Dmitrij Zagidulin, London, Canada
 Yanxiu Zhou, Phoenix, AZ
 Laurent Zinck, Mothern, France

Member Representatives

Zoraida Aguilar, Fayetteville, AR
 Paolina Atanassova, Albuquerque, NM
 William Bushong, Madison, WI
 Robert Roberts, Oak Ridge, TN
 Kazuhiko Shinohara, Kanagawa, Japan

■ NEW MEMBERS ■

Students

Muhammad Ali, Arlington, TX
 Saeed Amirjalayer, Bochum, Germany
 David Baker, South Bend, IN
 George Bandlamudi, Duisburg, Germany
 Wonbae Bang, Daejeon, South Korea
 Jianli Bao, Fife, Scotland
 Aleksandr Bessonov, Novosibirsk, Russia
 Derek Beving, Riverside, CA
 Rui Cai, Pasadena, CA
 Amartya Chakrabarti, Chicago, IL
 Yun-Min Chang, Hsinchu, Taiwan
 Mo Huai Chang, Liverpool, United Kingdom
 Mu-Tung Chang, Hsinchu, Taiwan
 Zhebo Chen, Stanford, CA
 Xudong Chen, Miami, FL
 Bruno de Matos, Sao Paulo, Brazil
 Sameer Deshpande, Orlando, FL
 Carlos Driemeier, Rio Grande do Sol, Brazil
 Margaret Dudley, Dallastown, PA
 Hung Duong, Urbana, IL
 Nnabuk Eddy, Akwa Ibom State, Nigeria
 Jennifer Fedorowski, Baltimore, MD
 Hsien Ping Feng, Hsinchu, Taiwan
 Pierre Ferguson, Halifax, Canada
 Aja Fernengel, Richfield, OH
 Roland Friedmann, Lawrence, KS
 Olt Geiculescu, Easley, SC
 Ayan Ghosh, Hyattsville, MD
 Joshua Golbert, London, United Kingdom
 Ying Gong, Singapore
 Yelena Gorlin, Stanford, CA
 Chaokang Gu, Auburn, AL
 Jeong-Hee Ha, Stanford, CA
 Bin Hai, Cleveland, OH
 Peter Hallac, Central, SC
 Xiaofei Han, Arlington, TX
 Naoya Hayamizu, Yokohama, Japan
 Mahesha Herath, Clemson, SC
 Yen-Jung Huang, Cleveland Heights, OH
 Chi-Te Huang, Hsinchu, Taiwan
 Mohd Sobri Idris, Sheffield, United Kingdom
 Hanan Idrisi, Frankfurt am Main, Germany
 David Ingram, Ann Arbor, MI
 Donghyup Jeon, Columbia, SC
 Kimberley Jones, Preston, United Kingdom
 Sean Keuleyan, Philadelphia, PA
 Manish Khandelwal, State College, PA
 Soowhan Kim, State College, PA
 Seung Hyun Kim, Staanford, CA
 Damian Kowalski, Sapporo, Japan
 Kristyna Kubickova, Brno, Czech Republic
 Chun-Han Lai, Hsin-Chu, Taiwan
 Rinus Lee, Singapore
 Rolan Lewis, Toronto, Canada
 Emily Lewis, Boston, MA
 Jing Li, Halifax, Canada
 Peng Liao, Halifax, Canada
 Ting Yi Lin, Hsinchu, Taiwan
 Guangjuan Liu, Austin, TX

Zhufang Liu, Tuscaloosa, AL
 Zengcai Liu, Houston, TX
 Haiping Liu, Wei-Hai, China
 Xiaochuan Lu, Cookeville, TN
 Zhouguang Lu, Kowloon, Hong Kong
 Shalini Maheshwari, Tulsa, OK
 Prasanna Mani, Houston, TX
 Vincent Menard, Montreal, Canada
 Eliza Montgomery, University Park, PA
 Liadi Mudashiru, Newcastle Upon Tyne, United Kingdom
 Minoru Muranaka, Tokyo, Japan
 Ominda Nanayakkara, Tokyo, Japan
 Muhammad Adi Negara, Cork, Ireland
 Weina Peng, Madison, WI
 Emilie Perre, Uppsala, Sweden
 Kelly Perry, Troy, NY
 Harold Philipson, Meijel, The Netherlands
 Daniel Possner, Frankfurt, Germany
 Konlayutt Punyawudho, Columbia, SC
 Rama Rajagopal, Clemson, SC
 Elias Remita, Asnieres, France
 Yusuke Sasano, Nagoya, Japan
 George Scott, Terre Haute, IN
 Parinya Seelanan, London, United Kingdom
 Hemangi Shedge, Anderson, SC
 Dusan Spornjak, Newark, DE
 Dong Chan Suh, Seoul, South Korea
 Shuhui Sun, Varennes, Canada
 Yijun Tang, Rochester, MI
 Andrew Todd, Halifax, Canada
 Wei Tong, North Brunswick, NJ
 Masaru Tsuchiya, Cambridge, MA
 Etim Udoetok, Baton Rouge, LA
 Gus Vasquez, Los Alamos, NM
 Yasuaki Wakizaka, Southampton, United Kingdom
 Zhen Wang, Tokyo, Japan
 Chiu-Yen Wang, Hsinchu, Taiwan
 Yongjun Wang, Eugene, OR
 Yu-Lin Wang, Gainesville, FL
 John Wang, Glendora, CA
 Wichapun Weerapakkaron, Nagaoka, Japan
 Lawrence Weinstein, North Brunswick, NJ
 Wei-Ting Wu, Tanian, Taiwan
 Hui Xie, Dongguan, China
 Junhua Xin, Auburn, AL
 Mehdi Yekehtaz, Darmstadt, Germany
 Jae-Hwan Yi, Ansan, South Korea
 Chunjuan Zhang, Lincoln, NE
 Yao Zhang, Guangzhou, China
 HaiFeng Zhang, Kowloon, Hong Kong
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